

Positions Available

DEAN

School of Ceramic Engineering and Sciences

The New York State College of Ceramics at Alfred University announces a search for a Dean of its School of Ceramic Engineering and Sciences. The School, a companion to the College's School of Art and Design, currently has 25 faculty and approximately 400 undergraduate and 80 graduate students enrolled in programs leading to BS and MS degrees in Ceramic Engineering, Ceramic Engineering Science, Glass Engineering Science, and the PhD in Ceramics.

The new Dean will provide academic leadership to guide the School into the 21st century. He or she will report to Dr. J.W. McCauley, the Dean and Chief Administrative Officer of the New York State College of Ceramics. The successful candidate will have academic credentials appropriate to a tenurable full professor. Previous academic administrative experience is highly desirable.

The College, a statutory public sector unit of the State University of New York, is located at Alfred University, a private institution of 2,500 students, situated in a pleasant rural setting in Western New York, 70 miles south of Rochester.

Expressions of interest, nominations, or application packages should be addressed to:

Dr. Richard M. Spriggs
 J.F. McMahon Professor of Ceramic Engineering
 Chair, Dean's Search Committee
 New York State College of Ceramics at Alfred University
 Alfred, NY 14802 USA
 607-871-2486

Review of applications will begin December 1, 1991, and will continue until the position is filled. We hope to have the new Dean in place for the 1992/93 academic year.

The New York State College of Ceramics is an Affirmative Action, Equal Opportunity Employer. Women and minorities are encouraged to apply.

Positions Wanted

Experimental solid state physicist, PhD. Experience: multilayers, high-Tc superconductors, thin films; structural, electronic, and elastic properties. Technical background: thin film deposition, XRD, SAW, XPS, SAM, STM, resistivity. I seek a position in basic/applied research in materials, preferably thin films. Reply to Box No. 11-5, c/o MRS Bulletin.

Seeking position in industry or academia in the area of thin films, coating. 16 years hands-on experience in research, development and implementation of new methods in manufacturing. Technical skills: physical vapor deposition techniques, including evaporation, sputtering and ion-assisted film growth; ion and electron treatment. 15 papers and 4 patents. Reply to Box No. 11-7, c/o MRS Bulletin.

TO REPLY TO BOX NUMBER, WRITE:

Box No. _____, c/o MRS Bulletin
 Materials Research Society
 9800 McKnight Road
 Pittsburgh, PA 15237

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POSTERMINARIES

***Slings and Arrows and
 Sticks and Stones -
 Technophile Style***

Is it ever amusing to be insulted? Have you ever not known if an apparent brickbat was intended as an insult or compliment? Do you encounter this dilemma more often with technical colleagues than lay people?

In response to comparatively overwhelming demand since the appearance in January of 1988 of our POSTERMINARIES on the "Technophile Telegraph," we list some more examples of the vernacular of lab chatter applied to human (as distinct from scientific) pursuits. Of course the supply of examples is asymptotically infinite, so we have limited our list to a portion of the two-word alliterative subset. Interested readers may let the MRS Bulletin know which sound insulting, flattering, or neutral and may send some examples of their own.

Imagine being told that one (or several) of the following attributes can be applied to you:

- Martensitic Mentality
- Inertial Indecisiveness
- Heat-and-Beat Bias*
- Tangential Temperament
- Insulated Indifference
- Planetary Personality
- Reactive Rhetoric
- Axiomatic Attitude
- Nebulous Notions
- Amorphous Approach
- Concrete Character
- Precipitating Posture
- Sagittal Stature
- Ternary Talents
- Orthogonal Optimism
- Dilute Disposition
- Stoichiometric Simplicity

*Not strictly a member of this set, but forced by entropic exigencies.

E.N. KAUFMANN